



# STIC Search Report

EIC 1700

STIC Database Tracking Number: EIC 1700

**TO:** John Goodrow  
**Location:** REM 10A45  
**Art Unit :** 1756  
**April 1, 2005**

**Case Serial Number:** 10/657484

**From:** Les Henderson  
**Location:** EIC 1700  
**REM 4B28 / 4A30**  
**Phone:** 571-272-2538

**Leslie.henderson@uspto.gov**

## Search Notes

There are no hits for the calcium diazo dye you submitted (L8). The compound is in the registry file (L7), but not even the application shows up yet in STN. I did find other salts and isomers, which are included.

=> d his

(FILE 'HOME' ENTERED AT 10:38:30 ON 01 APR 2005)

FILE 'HCA' ENTERED AT 10:38:41 ON 01 APR 2005

E 20050054385/PN  
E US20050054385/PN  
E BINDRA AMRIT/AU

L1 9 S E3-E5

L2 11364 S RED(2A)PIGMENT?

L3 2 S L1 AND L2  
SEL L3 RN

FILE 'REGISTRY' ENTERED AT 10:45:03 ON 01 APR 2005

L4 24 S E1-E24

FILE 'LREGISTRY' ENTERED AT 10:51:23 ON 01 APR 2005

FILE 'REGISTRY' ENTERED AT 11:04:50 ON 01 APR 2005

E C20H14N2O7S2.CA/MF  
L5 4 S C20H14N2O7S2.CA/MF  
E C20H14N2O7S2.CA/MF

L6 10 S E5-8

L7 1 S 83249-60-9/RN

FILE 'HCA' ENTERED AT 11:15:00 ON 01 APR 2005

E COMPOSITION/CT  
E COATING/CT

L8 0 S L7

FILE 'REGISTRY' ENTERED AT 11:19:43 ON 01 APR 2005

L9 1 S 141025-34-5/RN  
E 73019-25-7/RN

L10 1 S 73019-25-7/RN  
E 67990-37-8/RN

L11 1 S 67990-37-8/RN

FILE 'HCA' ENTERED AT 11:37:03 ON 01 APR 2005

FILE 'CAOLD' ENTERED AT 11:37:17 ON 01 APR 2005

L12 0 S L7

FILE 'HCAPLUS' ENTERED AT 11:38:18 ON 01 APR 2005

L13 0 S L7  
L14 1 S L9  
L15 0 S L10  
L16 0 S L11

FILE 'CAOLD' ENTERED AT 11:41:52 ON 01 APR 2005

L17 0 S L9-L11

FILE 'REGISTRY' ENTERED AT 11:42:29 ON 01 APR 2005

E C20H14N2O7S2.CA/MF  
E 410538-28-2/RN

L18 1 S 410538-28-2/RN  
E 250639-69-1/RN

L19 1 S 250639-69-1/RN  
E 139966-00-0/RN

L20 1 S 139966-00-0/RN

L21            E 90333-45-2/RN  
       1 S 90333-45-2/RN  
           E 62681-89-4/RN  
L22            1 S 62681-89-4/RN  
           E 62681-88-3/RN  
L23            1 S 62681-88-3/RN

FILE 'HCAPLUS' ENTERED AT 11:54:29 ON 01 APR 2005

L24            0 S L18  
L25            1 S L19  
L26            0 S L20  
L27            1 S L21  
L28            1 S L22  
L29            1 S L23

FILE 'CAOLD' ENTERED AT 11:56:51 ON 01 APR 2005

L30            0 S L18-L23

FILE 'REGISTRY' ENTERED AT 11:57:19 ON 01 APR 2005

L31            3 S L9-L11  
L32            6 S L18-L23

FILE 'HCAPLUS' ENTERED AT 11:59:32 ON 01 APR 2005

L33            4 S L14 OR L24-L29

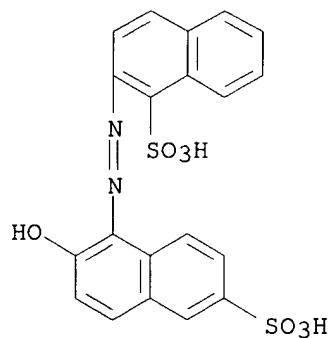
FILE 'REGISTRY' ENTERED AT 12:03:18 ON 01 APR 2005

=> d 17 all

L7    ANSWER 1 OF 1   REGISTRY   COPYRIGHT 2005 ACS on STN  
RN    **83249-60-9**   REGISTRY  
ED    Entered STN: 16 Nov 1984  
CN    1-Naphthalenesulfonic acid, 2-[(2-hydroxy-6-sulfo-1-naphthalenyl)azo]-, calcium salt (1:1) (9CI) (CA INDEX NAME)  
MF    C20 H14 N2 O7 S2 . Ca  
LC    STN Files: CHEMLIST  
Other Sources: DSL\*\*, EINECS\*\*, TSCA\*\*  
(\*\*Enter CHEMLIST File for up-to-date regulatory information)  
CRN   (111797-52-5)

#### Ring System Data

Elemental Analysis	Elemental Sequence	Size of the Rings	Ring Formula	Identifier	RID	Occurrence
EA	ES	SZ	RF	RID	Count	
C6-C6	C6-C6	6-6	C10	591.49.57	2	



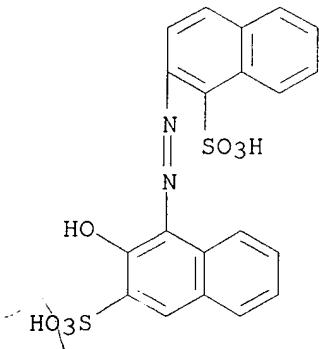
● Ca

=> d 131 1-3 all

L31 ANSWER 1 OF 3 REGISTRY COPYRIGHT 2005 ACS on STN  
RN 141025-34-5 REGISTRY  
ED Entered STN: 01 May 1992  
CN 1-Naphthalenesulfonic acid, 2-[(2-hydroxy-3-sulfo-1-naphthalenyl)azo]-, calcium salt (1:1) (9CI) (CA INDEX NAME)  
MF C20 H14 N2 O7 S2 . Ca  
SR CA  
LC STN Files: CA, CAPLUS  
DT.CA CAplus document type: Patent  
RL.P Roles from patents: USES (Uses)  
CRN (787518-41-6)

## Ring System Data

Elemental Analysis	Elemental Sequence	Size of the Rings	Size of the Rings	Ring System Formula	Identifier	Occurrence Count	Ring RID	Elemental RID
EA	ES	SZ	RF	RID	Count			
C6-C6	C6-C6	6-6	C10	591.49.57	2			



## ● Ca

1 REFERENCES IN FILE CA (1907 TO DATE)  
1 REFERENCES IN FILE CAPLUS (1907 TO DATE)

## REFERENCE 1

AN 116:257360 CA  
 TI Preparation of mixed laked azo pigments  
 IN Necas, Miroslav; Plechacek, Vaclav  
 PA Czech.  
 SO Czech., 4 pp.  
 CODEN: CZXXA9  
 DT Patent  
 LA Czech  
 IC ICM C09B065-00  
 CC 41-3 (Dyes, Organic Pigments, Fluorescent Brighteners, and Photographic Sensitizers)

## FAN.CNT 1

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PI CS 268606	B1	19900314	CS 1988-6215	19880919

PRAI CS 1988-6215 19880919  
 AB Red pigments for printing inks, varnishes, and plastics with brilliant modified shades are prepared by coupling a mixture containing 75-99.5% diazotized 2,4,5-H2N(R1)(R2)C6H2SO3H (R1, R2 = H, Cl, Me) and 0.5-25% diazotized 2,n-H2NC10H6SO3H (n = 1, 5, 6, 7, 8) with 3,2-HOC10H6CO2H (I) and laking the zo dye with Ca, Ba, Mg, Sr, or Mn. A mixture containing 96 mol% Ca salt of 2,4-HO3S MeC6H3NH2 → I (II) and 4 mol% Ca salt of 1,2-HO3SC10H6-NH2 → I was prepared in this way and had a more bluish shade than II.

ST azo pigment mixt lake

IT Pigments  
 (azo, laked, manufacture of mixed, with modified shade)

IT 81-16-3, 2-Naphthylamine-1-sulfonic acid 86-60-2,  
 2-Naphthylamine-8-sulfonic acid 88-44-8, 4-Aminotoluene-3-sulfonic acid 140921-46-6

RL: USES (Uses)  
 (coupling of diazotized, with hydroxynaphthoic acid)

IT 92-70-6, 3-Hydroxy-2-naphthoic acid

RL: RCT (Reactant); RACT (Reactant or reagent)  
 (coupling of, with mixts. of diazotized aminobenzene- and

-naphthalenesulfonic acids)

IT 73612-29-0 141025-33-4 141025-34-5 141025-35-6 141025-36-7  
141025-37-8

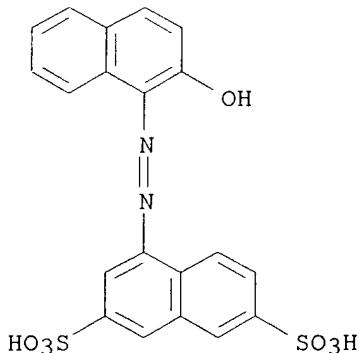
RL: USES (Uses)

(mixts. containing, manufacture of, as pigments)

L31 ANSWER 2 OF 3 REGISTRY COPYRIGHT 2005 ACS on STN  
 RN 73019-25-7 REGISTRY  
 ED Entered STN: 16 Nov 1984  
 CN 2,7-Naphthalenedisulfonic acid, 4-[{(2-hydroxy-1-naphthalenyl)azo}-,  
 calcium salt (1:1) (9CI) (CA INDEX NAME)  
 MF C20 H14 N2 O7 S2 . Ca  
 LC STN Files: CHEMLIST  
 Other Sources: NDSL\*\*, TSCA\*\*  
 (\*\*Enter CHEMLIST File for up-to-date regulatory information)  
 CRN (90339-80-3)

#### Ring System Data

Elemental Analysis	Elemental Sequence	Size of the Rings	Ring System	Ring Formula	Identifier	RID	Occurrence
EA	ES	SZ		RF	RID	Count	
C6-C6	C6-C6	6-6		C10	591.49.57	2	

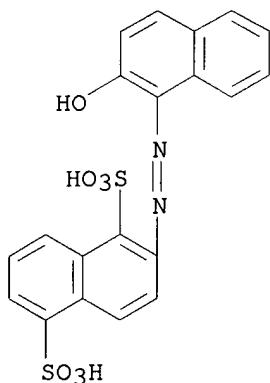


● Ca

L31 ANSWER 3 OF 3 REGISTRY COPYRIGHT 2005 ACS on STN  
 RN 67990-37-8 REGISTRY  
 ED Entered STN: 16 Nov 1984  
 CN 1,5-Naphthalenedisulfonic acid, 2-[{(2-hydroxy-1-naphthalenyl)azo}-,  
 calcium salt (1:1) (9CI) (CA INDEX NAME)  
 MF C20 H14 N2 O7 S2 . Ca  
 LC STN Files: CHEMLIST  
 Other Sources: EINECS\*\*, NDSL\*\*, TSCA\*\*  
 (\*\*Enter CHEMLIST File for up-to-date regulatory information)  
 CRN (116680-42-3)

## Ring System Data

Elemental Analysis	Elemental Sequence	Size of the Rings	Ring System Formula	Identifier	Occurrence
EA	ES	SZ	RF	RID	Count
C6-C6	C6-C6	6-6	C10	591.49.57	2



● Ca

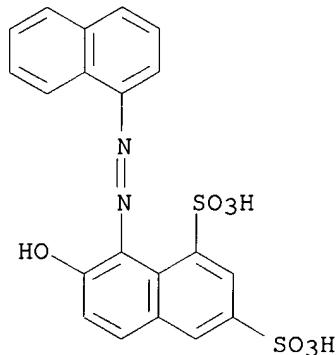
```
=> d que stat 132
L18      1 SEA FILE=REGISTRY ABB=ON    PLU=ON   410538-28-2/RN
L19      1 SEA FILE=REGISTRY ABB=ON    PLU=ON   250639-69-1/RN
L20      1 SEA FILE=REGISTRY ABB=ON    PLU=ON   139966-00-0/RN
L21      1 SEA FILE=REGISTRY ABB=ON    PLU=ON   90333-45-2/RN
L22      1 SEA FILE=REGISTRY ABB=ON    PLU=ON   62681-89-4/RN
L23      1 SEA FILE=REGISTRY ABB=ON    PLU=ON   62681-88-3/RN
L32      6 SEA FILE=REGISTRY ABB=ON    PLU=ON   (L18 OR L19 OR L20 OR
          L21 OR L22 OR L23)
```

=&gt; d 132 1-6 all

```
L32  ANSWER 1 OF 6  REGISTRY  COPYRIGHT 2005 ACS on STN
RN  410538-28-2  REGISTRY
ED  Entered STN: 03 May 2002
CN  1,3-Naphthalenedisulfonic acid, 7-hydroxy-8-(1-naphthalenylazo)-,
    monosodium salt (9CI) (CA INDEX NAME)
MF  C20 H14 N2 O7 S2 . Na
SR  Chemical Library
LC  STN Files: CHEMCATS
CRN (22915-90-8)
```

## Ring System Data

Elemental Analysis	Elemental Sequence	Size of the Rings	Ring System	Formula	Identifier	Occurrence	RID	Count
EA	ES	SZ		RF	RID			
C6-C6	C6-C6	6-6		C10	591.49.57	2		

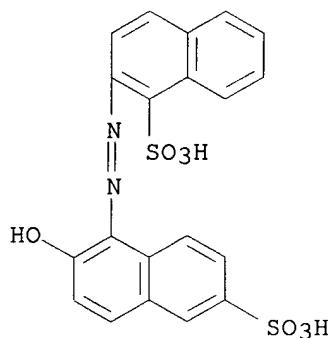


● Na

L32 ANSWER 2 OF 6 REGISTRY COPYRIGHT 2005 ACS on STN  
RN 250639-69-1 REGISTRY  
ED Entered STN: 13 Dec 1999  
CN 1-Naphthalenesulfonic acid, 2-[(2-hydroxy-6-sulfo-1-naphthalenyl)azo]-, strontium salt (1:1) (9CI) (CA INDEX NAME)  
MF C20 H14 N2 O7 S2 . Sr  
SR CAS Client Services  
LC STN Files: CA, CAPLUS, USPATFULL  
DT.CA CAplus document type: Patent  
RL.P Roles from patents: PREP (Preparation)  
CRN (111797-52-5)

#### Ring System Data

Elemental Analysis	Elemental Sequence	Size of the Rings	Ring System	Formula	Identifier	Occurrence	RID	Count
EA	ES	SZ		RF	RID			
C6-C6	C6-C6	6-6		C10	591.49.57	2		



● Sr

1 REFERENCES IN FILE CA (1907 TO DATE)  
1 REFERENCES IN FILE CAPLUS (1907 TO DATE)

## REFERENCE 1

AN 142:262349 CA  
TI Heat stable laked monoazo red pigment and its manufacture  
IN Bindra, Amrit P.  
PA USA  
SO U.S. Pat. Appl. Publ., 11 pp.  
CODEN: USXXCO  
DT Patent  
LA English  
IC ICM C09D011-00  
ICS G03G009-00  
NCL 106031800  
CC 37-6 (Plastics Manufacture and Processing)  
Section cross-reference(s): 41, 42

FAN.CNT 1  
PATENT NO.            KIND    DATE                    APPLICATION NO.    DATE

PI	US 2005051050	A1	20050310	US 2003-657485	20030908
	WO 2005026264	A1	20050324	WO 2004-US28950	20040903
	W: AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NA, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE, SG, SK, SL, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW				
	RW: BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW, AM, AZ, BY, KG, KZ, MD, RU, TJ, TM, AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IT, LU, MC, NL, PL, PT, RO, SE, SI, SK, TR, BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG				

PRAI US 2003-657485 20030908

AB The title red pigment has a unique x-ray diffraction pattern. Use of certain surface active agents e.g. alkylamine-guanidine polyoxyethanol during the coupling reaction facilitates the subsequent formation of the laked monoazo red pigments in the  $\beta$

crystal form with a distinct X-ray diffraction pattern. The X-ray diffraction pattern comprises high diffraction intensities at diffraction angles of .apprx.10.4°, .apprx.17.5°, .apprx.18.7°, .apprx. 21.6° and .apprx.23°; moderate diffraction intensities at .apprx.14.4°, .apprx.15°, .apprx.24.4°, .apprx.24.8°, .apprx.25.2° and .apprx.26.2°; and low diffraction intensities at .apprx.about 15.4°, .apprx.17.5°, .apprx.17.8°, .apprx.19.3°, .apprx.20°, .apprx.21°, .apprx.21.8°, .apprx.26.6°, .apprx.28.6°, .apprx.30.2°, .apprx.31.6 °, .apprx.32.1°, .apprx.34.8° and .apprx.38°.

Also, the pH ranges described facilitate the formation of the laked monoazo red pigments in the β crystal form with a distinct X-ray diffraction pattern. Coating compns., ink compns., plastic compns., electrostatic toner compns., powder coating compns., paint compns., and paper compns. containing the red pigment have high chroma.

ST naphthalenesulfonic monoazo strontium salt pigment prepn

IT Amides, uses

RL: NUU (Other use, unclassified); USES (Uses)  
(coco, N-[3-(dimethylamino)propyl], N-oxides; heat stable laked monoazo red pigment)

IT Amine oxides

RL: NUU (Other use, unclassified); USES (Uses)  
(cocoalkyldimethyl; heat stable laked monoazo red pigment)

IT Azo dyes

Pigments, nonbiological  
(heat stable laked monoazo red pigment)

IT Coating materials

Electrographic toners

Inks

Surfactants

Viscose

(heat stable laked monoazo red pigment for)

IT Polyamides, uses

Polycarbonates, uses

Polyesters, uses

Polyimides, uses

Polyurethanes, uses

RL: TEM (Technical or engineered material use); USES (Uses)  
(heat stable laked monoazo red pigment for)

IT 41489-81-0, Sodium 2-hydroxynaphthalene-6-sulfonate

RL: RCT (Reactant); RACT (Reactant or reagent)  
(coupling component; heat stable laked monoazo red pigment)

IT 81-16-3, 2-Aminonaphthalene-1-sulfonic acid

RL: RCT (Reactant); RACT (Reactant or reagent)  
(diazotization; heat stable laked monoazo red pigment)

IT 1643-20-5, Lauryl dimethylamine oxide 2571-88-2,

Stearyldimethylamine oxide 3332-27-2, Myristyldimethylamine oxide 7128-91-8, Dimethylhexadecylamine oxide

RL: NUU (Other use, unclassified); USES (Uses)  
(heat stable laked monoazo red pigment)

IT 9003-53-6, Polystyrene 25014-41-9, Polyacrylonitrile

RL: TEM (Technical or engineered material use); USES (Uses)  
(heat stable laked monoazo red pigment for)

IT 9002-88-4, Polyethylene

RL: TEM (Technical or engineered material use); USES (Uses)  
(pigmented test piece; heat stable laked monoazo red pigment for)

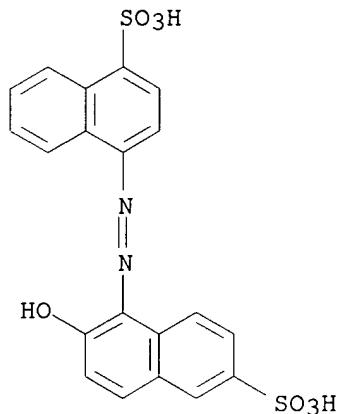
IT 250639-69-1P

RL: IMF (Industrial manufacture); PREP (Preparation)  
 (β crystal form; heat stable laked monoazo red pigment)

L32 ANSWER 3 OF 6 REGISTRY COPYRIGHT 2005 ACS on STN  
 RN **139966-00-0** REGISTRY  
 ED Entered STN: 27 Mar 1992  
 CN 1-Naphthalenesulfonic acid, 4-[(2-hydroxy-6-sulfo-1-naphthalenyl)azo]-, monosodium salt (9CI) (CA INDEX NAME)  
 MF C20 H14 N2 O7 S2 . Na  
 CI COM  
 SR CA  
 LC STN Files: BEILSTEIN\*  
 (\*File contains numerically searchable property data)  
 CRN (25317-26-4)

## Ring System Data

Elemental Analysis	Elemental Sequence	Size of the Rings	Ring Formula	Identifier	Occurrence
EA	ES	SZ	RF	RID	Count
C6-C6	C6-C6	6-6	C10	591.49.57	2

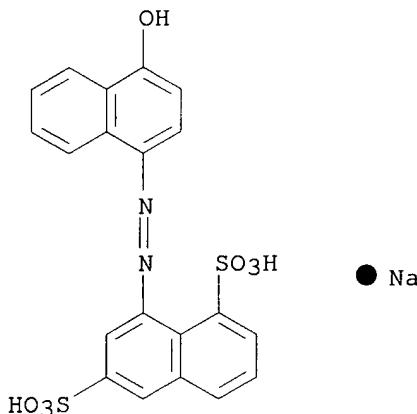


● Na

L32 ANSWER 4 OF 6 REGISTRY COPYRIGHT 2005 ACS on STN  
 RN **90333-45-2** REGISTRY  
 ED Entered STN: 16 Nov 1984  
 CN 1,6-Naphthalenedisulfonic acid, 8-[(4-hydroxy-1-naphthalenyl)azo]-, monopotassium monosodium salt (9CI) (CA INDEX NAME)  
 MF C20 H14 N2 O7 S2 . K . Na  
 LC STN Files: CA, CAPLUS  
 DT.CA CAPplus document type: Patent  
 RL.P Roles from patents: USES (Uses)  
 CRN (687614-15-9)

## Ring System Data

Elemental Analysis	Elemental Sequence	Size of the Rings	Ring System	Ring Formula	Identifier	Occurrence	RID	Count
EA C6-C6	ES C6-C6	SZ 6-6	RF C10	C10	1591.49.57	2		



● K

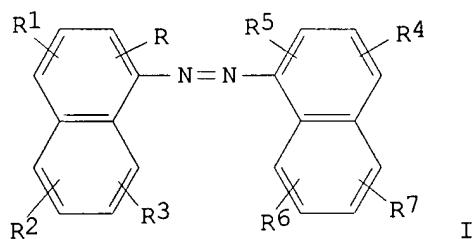
1 REFERENCES IN FILE CA (1907 TO DATE)  
 1 REFERENCES IN FILE CAPLUS (1907 TO DATE)

## REFERENCE 1

AN 101:25140 CA  
 TI Recording solutions  
 PA Canon K. K., Japan  
 SO Jpn. Kokai Tokkyo Koho, 7 pp.  
 CODEN: JKXXAF  
 DT Patent  
 LA Japanese  
 IC C09D011-00; C09D011-16  
 CC 42-12 (Coatings, Inks, and Related Products)  
 Section cross-reference(s): 41

## FAN.CNT 1

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
JP 58176260	A2	19831015	JP 1982-57985	19820409
PRAI JP 1982-57985		19820409		
GI				



AB The recording solns. contain compds. I [R, R<sub>1</sub>, R<sub>2</sub>, R<sub>3</sub> = H, halogen, OH, NO<sub>2</sub>, Me, OMe, SO<sub>3</sub>R<sub>8</sub>; R<sub>4</sub>, R<sub>5</sub>, R<sub>6</sub>, R<sub>7</sub> = H, OH, SO<sub>3</sub>R<sub>8</sub>; ≥1 substituent of R<sub>4-7</sub> is OH; R<sub>8</sub> = alkali metal, (substituted) ammonium, amine moiety] are claimed. The solns. for ink-jet recording containing I have excellent and well-balanced recording properties, storage stability, dissoln. stability in liquid solvents, and setting properties on printing paper, and give printed letters showing excellent weatherability, light resistance, water resistance, and alc. resistance. Thus, a SiO<sub>2</sub> layer was laminated onto an alumina plate by sputtering; a HfB<sub>2</sub> resistance-heating layer was laminated on the SiO<sub>2</sub> layer to give a resistance-heating pattern by selective etching, where a SiO<sub>2</sub> protective layer was laminated to give an elec. heat exchanger. A glass plate was connected with the exchanger so that its grooves agreed with the resistance-heating body to give a recording head. Sep., I (R<sub>6</sub> = 8-OH; R<sub>7</sub> = 6-SO<sub>3</sub>Na; R and R<sub>1-5</sub> = H) [90333-47-4] 3, diethylene glycol 25, N-methyl-2-pyrrolidinone 20, and H<sub>2</sub>O 52 parts were mixed and dissolved to give a solution, which was used with the above recording head to five 150 h of continuous recording.

ST azo jet printing ink; hydroxyazonaphthalene jet printing ink; recording head jet printing ink

IT Recording apparatus

(heads, photo-alumina-hafnium boron-glass, for jet-printing inks)

IT Dyes, azo  
(hydroxyazonaphthalenes, jet-printing inks containing, storage-stable, for continuous use)

IT Inks  
(jet-printing, hydroxyazonaphthalene-based, storage-stable, for continuous use)

2653-72-7	5851-03-6	5858-33-3	90333-33-8	90333-34-9
90333-35-0	90333-36-1	90333-37-2	90333-38-3	90333-39-4
90333-40-7	90333-41-8	90333-42-9	90333-43-0	90333-44-1
90333-45-2	90333-46-3	90333-47-4	90339-77-8	90339-81-4

IT RL: USES (Uses)  
(inks, jet-printing, storage-stable, for continuous use)

IT 7631-86-9, uses and miscellaneous

IT RL: USES (Uses)  
(laminates with aluminum and hafnium boride and glass, recording heads, for jet-printing inks)

IT 12007-23-7

IT RL: USES (Uses)  
(laminates with silica and alumina and glass, recording heads, for jet-printing inks)

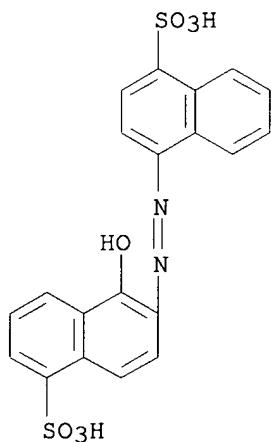
IT 1344-28-1, uses and miscellaneous

IT RL: USES (Uses)  
(laminates with silica and hafnium boride and glass, recording heads, for jet-printing inks)

L32 ANSWER 5 OF 6 REGISTRY COPYRIGHT 2005 ACS on STN  
 RN **62681-89-4** REGISTRY  
 ED Entered STN: 16 Nov 1984  
 CN 1-Naphthalenesulfonic acid, 5-hydroxy-6-[(4-sulfo-1-naphthalenyl)azo]-, monosodium salt, radical ion(1-) (9CI) (CA INDEX NAME)  
 MF C20 H14 N2 O7 S2 . Na  
 CI RIS  
 LC STN Files: CA, CAPLUS  
 DT.CA CAPLUS document type: Journal  
 RL.NP Roles from non-patents: RACT (Reactant or reagent)  
 CRN (763028-67-7)

## Ring System Data

Elemental Analysis	Elemental Sequence	Size of the Rings	Ring System Formula	Identifier	Occurrence
EA	ES	SZ	RF	RID	Count
C6-C6	C6-C6	6-6	C10	591.49.57	2



● Na

1 REFERENCES IN FILE CA (1907 TO DATE)  
 1 REFERENCES IN FILE CAPLUS (1907 TO DATE)

## REFERENCE 1

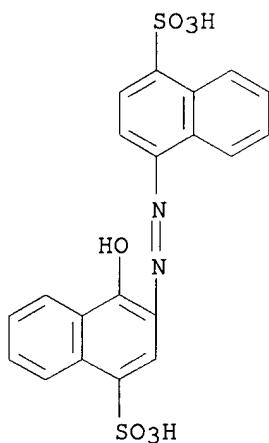
AN 86:170246 CA  
 TI ESR investigation of the radical intermediates formed in the photoreduction of azo dyes  
 AU Heijkoop, G.; Van Beek, H. C. A.  
 CS Lab. Chem. Technol., Univ. Technol., Delft, Neth.  
 SO Recueil des Travaux Chimiques des Pays-Bas (1977), 96(3), 83-5

CODEN: RTCPA3; ISSN: 0165-0513  
 DT Journal  
 LA English  
 CC 22-2 (Physical Organic Chemistry)  
 Section cross-reference(s): 40  
 AB ESR spectra of hydrazyl and aminonaphthoxy radicals formed upon photoredn. of azo dyes were measured. For the hydrazyl radicals the results obtained further confirm previous investigations of the mechanism of photoredn. of azo dyes. The direct identification in photoreduced dye solns. of aminonaphthoxy radicals, which are formed in the oxidation reduction equilibrium of aminonaphthols and iminoquinones provides strong evidence for previously proposed mechanisms for the disproportionation of hydrazyl radicals.  
 ST azo dye photoredn mechanism; ESR hydrazyl aminonaphthoxy  
 IT Radicals, preparation  
 RL: FORM (Formation, nonpreparative)  
 (formation of, in photoredn. of azo dyes, ESR of)  
 IT Electron spin resonance  
 (of aminonaphthoxy and hydrazyl radicals, from photoredn. of azo dyes)  
 IT Reduction, photochemical  
 (of azo dyes, ESR of radicals from)  
 IT Dyes, azo  
 (photoredn. of, ESR of radicals from)  
 IT 62681-71-4 62681-72-5 62681-73-6 62705-58-2  
 RL: PRP (Properties)  
 (ESR of)  
 IT 62681-88-3 62681-89-4 62681-90-7 62681-91-8 62681-92-9  
 RL: RCT (Reactant); RACT (Reactant or reagent)  
 (photoredn. of, ESR of radicals from)

L32 ANSWER 6 OF 6 REGISTRY COPYRIGHT 2005 ACS on STN  
 RN 62681-88-3 REGISTRY  
 ED Entered STN: 16 Nov 1984  
 CN 1-Naphthalenesulfonic acid, 4-hydroxy-3-[(4-sulfo-1-naphthalenyl)azo]-, monosodium salt, radical ion(1-) (9CI) (CA INDEX NAME)  
 MF C20 H14 N2 O7 S2 . Na  
 CI RIS  
 LC STN Files: CA, CAPLUS  
 DT.CA CAplus document type: Journal  
 RL.NP Roles from non-patents: RACT (Reactant or reagent)  
 CRN (783249-96-7)

## Ring System Data

Elemental Analysis	Elemental Sequence	Size of the Rings	Ring Formula	Identifier	Occurrence	Ring ID	Count
EA	ES	SZ	RF	RID			
C6-C6	C6-C6	6-6	C10	591.49.57	2		



● Na

1 REFERENCES IN FILE CA (1907 TO DATE)  
1 REFERENCES IN FILE CAPLUS (1907 TO DATE)

## REFERENCE 1

AN 86:170246 CA  
 TI ESR investigation of the radical intermediates formed in the photoreduction of azo dyes  
 AU Heijkoop, G.; Van Beek, H. C. A.  
 CS Lab. Chem. Technol., Univ. Technol., Delft, Neth.  
 SO Recueil des Travaux Chimiques des Pays-Bas (1977), 96(3), 83-5  
 CODEN: RTCPA3; ISSN: 0165-0513  
 DT Journal  
 LA English  
 CC 22-2 (Physical Organic Chemistry)  
 Section cross-reference(s): 40  
 AB ESR spectra of hydrazyl and aminonaphthoxy radicals formed upon photoredn. of azo dyes were measured. For the hydrazyl radicals the results obtained further confirm previous investigations of the mechanism of photoredn. of azo dyes. The direct identification in photoreduced dye solns. of aminonaphthoxy radicals, which are formed in the oxidation reduction equilibrium of aminonaphthols and iminoquinones provides strong evidence for previously proposed mechanisms for the disproportionation of hydrazyl radicals.  
 ST azo dye photoredn mechanism; ESR hydrazyl aminonaphthoxy  
 IT Radicals, preparation  
 RL: FORM (Formation, nonpreparative)  
 (formation of, in photoredn. of azo dyes, ESR of)  
 IT Electron spin resonance  
 (of aminonaphthoxy and hydrazyl radicals, from photoredn. of azo dyes)  
 IT Reduction, photochemical  
 (of azo dyes, ESR of radicals from)  
 IT Dyes, azo  
 (photoredn. of, ESR of radicals from)  
 IT 62681-71-4 62681-72-5 62681-73-6 62705-58-2

RL: PRP (Properties)  
 (ESR of)  
 IT 62681-88-3 62681-89-4 62681-90-7 62681-91-8 62681-92-9  
 RL: RCT (Reactant); RACT (Reactant or reagent)  
 (photoredn. of, ESR of radicals from)

=> => d que stat 133

L9	1 SEA FILE=REGISTRY ABB=ON	PLU=ON	141025-34-5/RN
L14	1 SEA FILE=HCAPLUS ABB=ON	PLU=ON	L9
L18	1 SEA FILE=REGISTRY ABB=ON	PLU=ON	410538-28-2/RN
L19	1 SEA FILE=REGISTRY ABB=ON	PLU=ON	250639-69-1/RN
L20	1 SEA FILE=REGISTRY ABB=ON	PLU=ON	139966-00-0/RN
L21	1 SEA FILE=REGISTRY ABB=ON	PLU=ON	90333-45-2/RN
L22	1 SEA FILE=REGISTRY ABB=ON	PLU=ON	62681-89-4/RN
L23	1 SEA FILE=REGISTRY ABB=ON	PLU=ON	62681-88-3/RN
L24	0 SEA FILE=HCAPLUS ABB=ON	PLU=ON	L18
L25	1 SEA FILE=HCAPLUS ABB=ON	PLU=ON	L19
L26	0 SEA FILE=HCAPLUS ABB=ON	PLU=ON	L20
L27	1 SEA FILE=HCAPLUS ABB=ON	PLU=ON	L21
L28	1 SEA FILE=HCAPLUS ABB=ON	PLU=ON	L22
L29	1 SEA FILE=HCAPLUS ABB=ON	PLU=ON	L23
L33	4 SEA FILE=HCAPLUS ABB=ON	PLU=ON	L14 OR (L24 OR L25 OR L26 OR L27 OR L28 OR L29)

=> d 133 1-4 ibib abs hitstr hitind

L33 ANSWER 1 OF 4 HCAPLUS COPYRIGHT 2005 ACS on STN  
 ACCESSION NUMBER: 2005:219481 HCAPLUS  
 DOCUMENT NUMBER: 142:262349  
 TITLE: Heat stable laked monoazo red pigment and its  
 manufacture  
 INVENTOR(S): Bindra, Amrit P.  
 PATENT ASSIGNEE(S): USA  
 SOURCE: U.S. Pat. Appl. Publ., 11 pp.  
 CODEN: USXXCO  
 DOCUMENT TYPE: Patent  
 LANGUAGE: English  
 FAMILY ACC. NUM. COUNT: 1  
 PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
-----	----	-----	-----	-----
US 2005051050	A1	20050310	US 2003-657485	200309 08
WO 2005026264	A1	20050324	WO 2004-US28950	200409 03

W: AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA,  
 CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI,  
 GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP,  
 KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW,  
 MX, MZ, NA, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD,  
 SE, SG, SK, SL, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ,  
 VC, VN, YU, ZA, ZM, ZW  
 RW: BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW,

AM, AZ, BY, KG, KZ, MD, RU, TJ, TM, AT, BE, BG, CH, CY, CZ,  
 DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IT, LU, MC, NL, PL,  
 PT, RO, SE, SI, SK, TR, BF, BJ, CF, CG, CI, CM, GA, GN, GQ,  
 GW, ML, MR, NE, SN, TD, TG

PRIORITY APPLN. INFO.:

US 2003-657485

A

200309

08

AB The title red pigment has a unique x-ray diffraction pattern. Use of certain surface active agents e.g. alkylamine-guanidine polyoxyethanol during the coupling reaction facilitates the subsequent formation of the laked monoazo red pigments in the  $\beta$  crystal form with a distinct X-ray diffraction pattern. The X-ray diffraction pattern comprises high diffraction intensities at diffraction angles of .apprx.10.4°, .apprx.17.5°, .apprx.18.7°, .apprx. 21.6° and .apprx.23°; moderate diffraction intensities at .apprx.14.4°, .apprx.15°, .apprx.24.4°, .apprx.24.8°, .apprx.25.2° and .apprx.26.2°; and low diffraction intensities at .apprx.about 15.4°, .apprx.17.5°, .apprx.17.8°, .apprx.19.3°, .apprx.20°, .apprx.21°, .apprx.21.8°, .apprx.26.6°, .apprx.28.6°, .apprx.30.2°, .apprx.31.6 °, .apprx.32.1°, .apprx.34.8° and .apprx.38°. Also, the pH ranges described facilitate the formation of the laked monoazo red pigments in the  $\beta$  crystal form with a distinct X-ray diffraction pattern. Coating compns., ink compns., plastic compns., electrostatic toner compns., powder coating compns., paint compns., and paper compns. containing the red pigment have high chroma.

IT

**250639-69-1P**

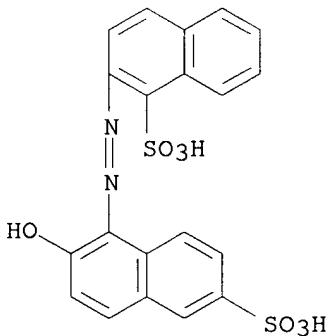
RL: IMF (Industrial manufacture); PREP (Preparation)  
 ( $\beta$  crystal form; heat stable laked monoazo red pigment)

RN

250639-69-1 HCPLUS

CN

1-Naphthalenesulfonic acid, 2-[(2-hydroxy-6-sulfo-1-naphthalenyl)azo]-, strontium salt (1:1) (9CI) (CA INDEX NAME)



● Sr

IC ICM C09D011-00  
 ICS G03G009-00

NCL 106031800; 106494000; 106402000; 106496000; 534581000; 534602000;  
 534883000; 524190000; 430108230

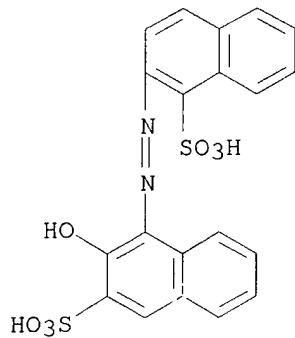
CC 37-6 (Plastics Manufacture and Processing)  
 Section cross-reference(s): 41, 42  
 IT **250639-69-1P**  
 RL: IMF (Industrial manufacture); PREP (Preparation)  
 ( $\beta$  crystal form; heat stable laked monoazo red pigment)

L33 ANSWER 2 OF 4 HCAPLUS COPYRIGHT 2005 ACS on STN  
 ACCESSION NUMBER: 1992:257360 HCAPLUS  
 DOCUMENT NUMBER: 116:257360  
 TITLE: Preparation of mixed laked azo pigments  
 INVENTOR(S): Necas, Miroslav; Plechacek, Vaclav  
 PATENT ASSIGNEE(S): Czech.  
 SOURCE: Czech., 4 pp.  
 CODEN: CZXXA9  
 DOCUMENT TYPE: Patent  
 LANGUAGE: Czech  
 FAMILY ACC. NUM. COUNT: 1  
 PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
CS 268606	B1	19900314	CS 1988-6215	198809 19
PRIORITY APPLN. INFO.:			CS 1988-6215	198809 19

OTHER SOURCE(S): MARPAT 116:257360  
 AB Red pigments for printing inks, varnishes, and plastics with  
 brilliant modified shades are prepared by coupling a mixture containing  
 75-99.5% diazotized 2,4,5-H<sub>2</sub>N(R<sub>1</sub>)(R<sub>2</sub>)C<sub>6</sub>H<sub>2</sub>SO<sub>3</sub>H (R<sub>1</sub>, R<sub>2</sub> = H, Cl, Me)  
 and 0.5-25% diazotized 2,n-H<sub>2</sub>NC<sub>10</sub>H<sub>6</sub>SO<sub>3</sub>H (n = 1, 5, 6, 7, 8) with  
 3,2-HOC<sub>10</sub>H<sub>6</sub>CO<sub>2</sub>H (I) and laking the zo dye with Ca, Ba, Mg, Sr, or  
 Mn. A mixture containing 96 mol% Ca salt of 2,4-HO<sub>3</sub>S MeC<sub>6</sub>H<sub>3</sub>NH<sub>2</sub> → I  
 (II) and 4 mol% Ca salt of 1,2-HO<sub>3</sub>SC<sub>10</sub>H<sub>6</sub>-NH<sub>2</sub> → I was prepared  
 in this way and had a more bluish shade than II.

IT **141025-34-5**  
 RL: USES (Uses)  
 (mixts. containing, manufacture of, as pigments)  
 RN 141025-34-5 HCAPLUS  
 CN 1-Naphthalenesulfonic acid, 2-[(2-hydroxy-3-sulfo-1-naphthalenyl)azo]-, calcium salt (1:1) (9CI) (CA INDEX NAME)



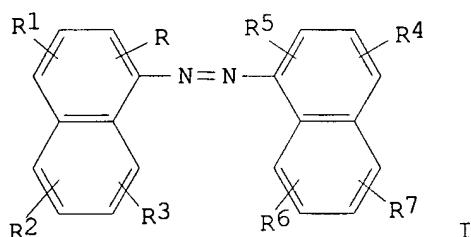
Ca

IC ICM C09B065-00  
CC 41-3 (Dyes, Organic Pigments, Fluorescent Brighteners, and  
Photographic Sensitizers)  
IT 73612-29-0 141025-33-4 **141025-34-5** 141025-35-6  
141025-36-7 141025-37-8  
RL: USES (Uses)  
(mixts. containing, manufacture of, as pigments)

L33 ANSWER 3 OF 4 HCAPLUS COPYRIGHT 2005 ACS on STN  
ACCESSION NUMBER: 1984:425140 HCAPLUS  
DOCUMENT NUMBER: 101:25140  
TITLE: Recording solutions  
PATENT ASSIGNEE(S): Canon K. K., Japan  
SOURCE: Jpn. Kokai Tokkyo Koho, 7 pp.  
CODEN: JKXXAF  
DOCUMENT TYPE: Patent  
LANGUAGE: Japanese  
FAMILY ACC. NUM. COUNT: 1  
PATENT INFORMATION:

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
JP 58176260	A2	19831015	JP 1982-57985	198204 09
PRIORITY APPLN. INFO.:			JP 1982-57985	198204 09

GI

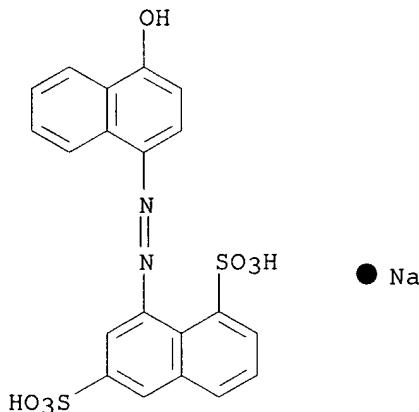


**AB** The recording solns. contain compds. I [R, R<sub>1</sub>, R<sub>2</sub>, R<sub>3</sub> = H, halogen, OH, NO<sub>2</sub>, Me, OMe, SO<sub>3</sub>R<sub>8</sub>; R<sub>4</sub>, R<sub>5</sub>, R<sub>6</sub>, R<sub>7</sub> = H, OH, SO<sub>3</sub>R<sub>8</sub>; ≥1 substituent of R<sub>4-7</sub> is OH; R<sub>8</sub> = alkali metal, (substituted) ammonium, amine moiety] are claimed. The solns. for ink-jet recording containing I have excellent and well-balanced recording properties, storage stability, dissoln. stability in liquid solvents, and setting properties on printing paper, and give printed letters showing excellent weatherability, light resistance, water resistance, and alc. resistance. Thus, a SiO<sub>2</sub> layer was laminated onto an alumina plate by sputtering; a HfB<sub>2</sub> resistance-heating layer was laminated on the SiO<sub>2</sub> layer to give a resistance-heating pattern by selective etching, where a SiO<sub>2</sub> protective layer was laminated to give an elec. heat exchanger. A glass plate was connected with the exchanger so that its grooves agreed with the resistance-heating body to give a recording head. Sep., I (R<sub>6</sub> = 8-OH; R<sub>7</sub> - 6-SO<sub>3</sub>Na; R and R<sub>1-5</sub> = H) [90333-47-4] 3, diethylene glycol 25, N-methyl-2-pyrrolidinone 20, and H<sub>2</sub>O 52 parts were mixed and dissolved to give a solution, which was used with the above recording head to five 150 h of continuous recording.

**IT** **90333-45-2**  
**RL:** USES (Uses)  
 (inks, jet-printing, storage-stable, for continuous use)

**RN** 90333-45-2 HCPLUS

**CN** 1,6-Naphthalenedisulfonic acid, 8-[(4-hydroxy-1-naphthalenyl)azo]-, monopotassium monosodium salt (9CI) (CA INDEX NAME)

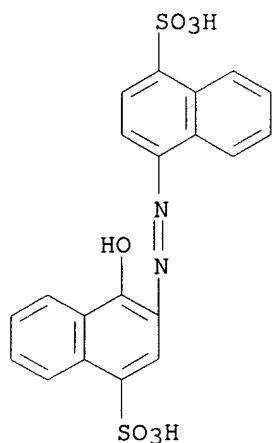


IC C09D011-00; C09D011-16  
 CC 42-12 (Coatings, Inks, and Related Products)  
 Section cross-reference(s): 41  
 IT 2653-72-7 5851-03-6 5858-33-3 90333-33-8 90333-34-9  
 90333-35-0 90333-36-1 90333-37-2 90333-38-3 90333-39-4  
 90333-40-7 90333-41-8 90333-42-9 90333-43-0 90333-44-1  
**90333-45-2** 90333-46-3 90333-47-4 90339-77-8  
 90339-81-4  
 RL: USES (Uses)  
 (inks, jet-printing, storage-stable, for continuous use)

L33 ANSWER 4 OF 4 HCAPLUS COPYRIGHT 2005 ACS on STN  
 ACCESSION NUMBER: 1977:170246 HCAPLUS  
 DOCUMENT NUMBER: 86:170246  
 TITLE: ESR investigation of the radical intermediates  
 formed in the photoreduction of azo dyes  
 AUTHOR(S): Heijkoop, G.; Van Beek, H. C. A.  
 CORPORATE SOURCE: Lab. Chem. Technol., Univ. Technol., Delft,  
 Neth.  
 SOURCE: Recueil des Travaux Chimiques des Pays-Bas  
 (1977), 96(3), 83-5  
 CODEN: RTCPA3; ISSN: 0165-0513

DOCUMENT TYPE: Journal  
 LANGUAGE: English  
 AB ESR spectra of hydrazyl and aminonaphthoxy radicals formed upon  
 photoredn. of azo dyes were measured. For the hydrazyl radicals the  
 results obtained further confirm previous investigations of the  
 mechanism of photoredn. of azo dyes. The direct identification in  
 photoreduced dye solns. of aminonaphthoxy radicals, which are formed  
 in the oxidation reduction equilibrium of aminonaphthols and iminoquinones  
 provides strong evidence for previously proposed mechanisms for the  
 disproportionation of hydrazyl radicals.

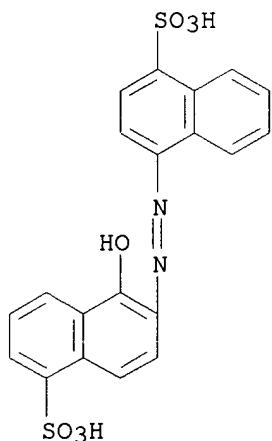
IT **62681-88-3 62681-89-4**  
 RL: RCT (Reactant); RACT (Reactant or reagent)  
 (photoredn. of, ESR of radicals from)  
 RN 62681-88-3 HCAPLUS  
 CN 1-Naphthalenesulfonic acid, 4-hydroxy-3-[(4-sulfo-1-  
 naphthalenyl)azo]-, monosodium salt, radical ion(1-) (9CI) (CA  
 INDEX NAME)



● Na

RN 62681-89-4 HCPLUS

CN 1-Naphthalenesulfonic acid, 5-hydroxy-6-[(4-sulfo-1-naphthalenyl)azo]-, monosodium salt, radical ion(1-) (9CI) (CA INDEX NAME)



● Na

CC 22-2 (Physical Organic Chemistry)

Section cross-reference(s): 40

IT 62681-88-3 62681-89-4 62681-90-7 62681-91-8

62681-92-9

RL: RCT (Reactant); RACT (Reactant or reagent)  
(photoredn. of, ESR of radicals from)